CLAIMS

What is claimed is:

1. An integrated circuit package comprising:

a substrate having first and second surfaces and a plurality of conductive traces therebetween:

a semiconductor die flip-chip mounted to said first surface of said substrate and electrically connected to ones of said conductive traces;

an intermetallic heat spreader fixed to a back side of said semiconductor die; and a plurality of contact balls disposed on said second surface of said substrate, in the form of a ball grid array, ones of said contact balls of said ball grid array being electrically connected with ones of said conductive traces.

- 2. The integrated circuit package according to claim 1, wherein said semiconductor die is flip-chip mounted to said first surface of said substrate and electrically connected to ones of said conductive traces via a plurality of solder ball connectors.
- 3. The integrated circuit package according to claim 2, further comprising an underfill material surrounding said solder ball connectors.
- 4. The integrated circuit package according to claim 1, wherein said solder ball connectors are comprised of eutectic solder.
- 5. The integrated circuit package according to claim 1, wherein said intermetallic heat spreader is fixed to said back side of said semiconductor die by a thermally conductive adhesive.
- 6. The integrated circuit package according to claim 1, wherein said intermetallic heat spreader is fixed to said back side of said semiconductor die by a thermally conductive epoxy.
- 7. The integrated circuit package according to claim 1, wherein said intermetallic heat spreader comprises a first portion fixed to said back side of said semiconductor die and a plurality of sidewalls in contact with said substrate.

- 8. The integrated circuit package according to claim 7, wherein said sidewalls are fixed to said substrate.
- 9. The integrated circuit package according to claim 1, wherein said heat spreader is fixed to a plurality of intermediate sidewalls at a plurality of sites, each of said intermediate sidewalls being fixed to said substrate.
- 10. The integrated circuit package according to claim 9, wherein said intermediate sidewalls comprise an intermetallic material.
- 11. The integrated circuit package according to claim 1, wherein said intermetallic compound comprises an intermetallic compound having a coefficient of thermal expansion of from about 18 ppm/°C to about 26 ppm/°C.
- 12. The integrated circuit package according to claim 1, wherein said intermetallic compound comprises an intermetallic compound having a coefficient of thermal expansion of about 22 ppm/°C.
- 13. The integrated circuit package according to claim 1, wherein intermetallic compound comprises CuAl₃.
- 14. The integrated circuit package according to claim 1, wherein said intermetallic compound has a modulus of elasticity of at least the modulus of elasticity of the semiconductor die.
- 15. The integrated circuit package according to claim 1, wherein said intermetallic compound comprises NiAl.
 - 16. An integrated circuit package comprising:

a substrate having first and second surfaces and a plurality of conductive traces therebetween;

a semiconductor die flip-chip mounted to said first surface of said substrate and electrically connected to ones of said conductive traces;

a heat spreader having a coefficient of thermal expansion in the range of about 18 ppm/°C to about 26 ppm/°C, fixed to a back side of said semiconductor die; and a plurality of contact balls disposed on said second surface of said substrate, in the form of a ball grid array, ones of said contact balls of said ball grid array being electrically connected with ones of said conductive traces.

- 17. The integrated circuit package according to claim 16, wherein the heat spreader has a coefficient of thermal expansion of about 22 ppm/°C.
- 18. The integrated circuit package according to claim 16, wherein said intermetallic compound has a modulus of elasticity of at least the modulus of elasticity of the semiconductor die.